

METHOD FOR MANUFACTURING INDIUM COMPLEX OR ITS TAUTOMER

Patent number: JP2002105055
Publication date: 2002-04-10
Inventor: KIMURA KEIZO; IGARASHI TATSUYA
Applicant: FUJI PHOTO FILM CO LTD
Classification:
- International: C07D213/16; C07D213/64; C07D213/70; C07D213/72;
C07D221/10; C07D231/12; C07D241/12; C07D249/04;
C07D277/66; C07D401/04; C07D405/04; C07D409/04;
C07D417/04; C07F15/00
- european:
Application number: JP20000298529 20000929
Priority number(s):

Report a data error here

Abstract of JP2002105055

PROBLEM TO BE SOLVED: To provide a method for manufacturing an indium complex compound useful as a material for a light emission element, especially various kinds of ortho-metalated complex of indium (III) which are particularly useful, easily in high yield.
SOLUTION: A method for manufacturing an ortho-metalated complex of indium (III) using an indium complex having a specific structure or its tautomer as a raw material.

Data supplied from the **esp@cenet** database - Patent Abstracts of Japan

BEST AVAILABLE COPY